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<b>Serial No.:</b>	09/995,880	<b>Art Unit:</b>	1752
<b>Filed:</b>	November 28, 2001	<b>Docket:</b>	50884 (17294)
<b>For:</b>	PHOTORESIST COMPOSITION		
<b>Conf. No.:</b>	1611	<b>Dated:</b>	July 31, 2006

**RESPONSE UNDER 37 C.F.R. § 1.111**

In response to the Office Action dated December 14, 2006, applicants submit the following amendments and remarks for entry of record in the above-identified patent application.

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on **May 14, 2007**.

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